

POSTER SESSIONS

Poster Session #1 - Tuesday 23 September (17:30 – 19:30)

MODIDD / Modelling, diagnostics and data-driven optimization of plasma processes

- #036** Open-source modeling of gas phase dynamics in industrial magnetron sputtering processes
J. Beyer, P. Nizenkov, S. Copplestone, A. Mirza
boltzplatz - numerical plasma dynamics GmbH - Stuttgart (DE)

- #073** Rotational temperature measurements of N₂(C), NO(A), and OH(A) in different micro hollow cathode discharge configurations using Optical Emission Spectroscopy
D. Stefanis¹, G. Makrypodi², B. Menacer¹, P. Svarnas², G. Lombardi¹, C. Lazzaroni¹, K. Gazeli¹
¹ LSPM - CNRS & Univ. Sorbonne Paris Nord - Villetaneuse (FR)
² High Voltage Lab., Electrical & Computer Eng. Dept., Univ. Patras - Rion (GR)

- #081** Assessing actinometry and line ratio techniques for species densities and electric field determination in DC glow discharges
T. Silva¹, L. Kuijpers², E. Baratte³, V. Guerra¹, R. Van De Sanden², J.P. Booth³, O. Guaitella³
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² Dutch Institute for Fundamental Energy Research (DIFFER) - Eindhoven, (NL)
³ Laboratoire de Physique des Plasmas (LPP) - Paris (FR)

- #094** Two dimensional distribution of atomic nitrogen absolute density in three DC MHCD
K. Gazeli¹, A. Remigy¹, B. Menacer¹, K. Kourtzanidis², O. Gazeli³, G. Lombardi¹, C. Lazzaroni¹
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³ FOSS Research Centre for Sustainable Energy, Univ. Cyprus - Nicosia (CY)

- #095** Analysis of sputtered species transport in High Power Impulse Magnetron Sputtering (HiPIMS) discharge employing magnetized QCM probe
A. Kapran¹, C. Ballage¹, Z. Hubička², T. Minea¹
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² FZU - Institute of Physics of the Czech Academy of Sciences - Prague (CZ)

- #101** Plasma-surface interactions in CO₂ glow discharges
V. Guerra¹, B. Berdugo², A. Filipe¹, O. Guaitella², A.S. Morillo Candás², P. Viegas¹
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² LPP, CNRS, Sorbonne Univ., École Polytechnique, Institut Polytechnique de Paris - Palaiseau (FR)

- #153** Study of the plasma pyrolysis of methane in a rotating gliding arc for carbon black synthesis
N. Roy¹, A. Panepinto², T. Godfroid², F. Mazeri², A. Usoltseva³, V. Smits³, R. Snyders^{1,2}
¹ Plasma-Surface Interaction Chemistry (ChIPS), Univ. Mons (BE)
² Materia Nova Research Center, Mons (BE)
³ Innovation Centre, Phillips Carbon Black Limited, Ghislenghien (BE)

- #157** Time-resolved measurements of secondary electron emission during ion bombardment
S. Mändl¹, H. Kersten², D. Manova¹
¹ Leibniz Institute of Surface Engineering (IOM) - Leipzig (DE)
² Institut für Experimentelle und Angewandte Physik, Christian-Albrechts-Universität Kiel - Kiel (DE)

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AMELI / Plasma and/in liquids interaction

- #053 Slow pulsed sputtering onto liquid: importance of surface refreshment and of plasma heating
A. Caillard, S. Atmane, A. Diop, E. Millon, P. Brault
GREMI CNRS / Univ. Orléans (FR)
- #128 The influence of the discharge parameters on the physicochemical properties of plasma activated water
L. Marcinauskas¹, E. Jankaitytė², M. Aikas¹, L. Ragelienė², R. Uscila¹, A. Tamošiūnas¹, Z. Naučienė², V. Mildažienė²
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² *Faculty of Natural Sciences, Vytautas Magnus Univ. - Kaunas (LT)*
- #146 Exfoliation and functionalization of graphite particles by pulsed plasma discharges in the gas-liquid phase
A. Requig, R. Chevigny, S. Cuynet, S. Fontana, C. Herold-Mareche, M. Ponçot, L. Adrien
Institut Jean Lamour, UMR 7198 CNRS – Univ. Lorraine - Nancy (FR)
- #147 Enhancement of grain quality of brewer's rice cultivar with plasma treatment of caryopsis using "Smart Agriculture System" based on collected data
M. Hori, H. Hashizume
Nagoya Univ. - Nagoya (JP)
- #154 Optimizing ammonia decomposition for enhanced hydrogen production in a novel rotating gliding arc reactor
M. Garcia Martinez¹, S. Marin-Meana², A. Megías-Sánchez², M. Ruiz-Martin², J. Cotrino², A. González-Elipe², M. Oliva-Ramírez³, A. Gómez-Ramírez³
¹ *Univ. Cordoba (ES)*
² *Instituto de Ciencia de Materiales de Sevilla (ES)*
³ *Univ. Sevilla (ES)*
- #160 Liquid flow control in a dual-frequency APPJ on water solutions
R. Fiorotto, E. Shakerinasab, M. Pierno, A. Patelli
Department of Physics and Astronomy "G. Galilei", Univ. Padova (IT)

Poster Session #1 - Tuesday 23 September (17:30 – 19:30)**ITEC / Innovative applications, solutions and technologies**

- #062 Functionalized amorphous carbon coatings for low secondary electron yield and controlled surface resistance in particle accelerators

W. Vollenberg¹, P. Costa Pinto¹, L. Mourier¹, Y. Rabetsimialona¹, N. Bundaleski², I.M. Marrucho Ferreira², J. Deuermeier²

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- #064 A low-temperature synthesis of strongly thermochromic VO₂-based coatings for energy-saving smart windows

M. Kaufman, E. M. Nia, J. Vlcek

Department of Physics and NTIS - European Centre of Excellence, Univ. West Bohemia, Pilsen (CZ)

- #085 Magnetron deposition of chromogenic thin films for smart windows

J. Purans, M. Zubkins

Institute of Solid State Physics, Univ. Latvia - Riga (LT)

- #129 Transforming Leak Detection in Vacuum environment with Remote Plasma Optical Emission Spectroscopy

B. Daniel^{1,2,3}

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² Gencoal Ltd - Marcus Law (UK)

³ Gencoal Ltd - Oisin Boyle (UK)

Poster Session #1 - Tuesday 23 September (17:30 – 19:30)

DEPO / Plasma-assisted deposition, coatings and layers

#013 Elaboration of 316L/Cu composite alloy using a hybrid PVD/SPS process

Y. Pinot¹, A. Besnard², M.R. Ardigo-Besnard³, F. Bussiere³

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#027 Development and investigation of advanced coatings for high-temperature applications

I. Toumi¹, S. Achache¹, A. Al Hussein¹, B. Panicaud²

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#050 Deposition of dielectric, and metal layer solution for TSV integration, innovative sequential process, application of low temperature deposition

M. Segers, P.D. Szkutnik, S. Benkoula

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#068 Development of hydrogen barrier thin films based on silicon carbonitride

M. Tetouani¹, A. Al Hussein¹, S. Achache¹, M. Cherkaoui²

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#072 Study of the impact of different dielectric materials on the performance and optical features of a Micro-Hollow Cathode Discharge (MHCD)

N. Chazapis, B. Menacer, D. Stefas, G. Lombardi, C. Lazzaroni, K. Gazeli

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#140 On thermal stability and oxidation behavior of metastable W–Zr thin-film alloys

M. Červená, J. Houška, R. Čerstvý, P. Zeman

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#141 Microstructural and mechanical properties of flash SPS WC-Co/AiSi 304L diffusion bonded

B. Maamache¹, N. Ouali¹, B. Belkessa¹, P. Hvizzdos², M. Fides², B. Cheniti¹

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² Institute of Materials Research, Slovak Academy of Sciences - Watsonova, Kosice (SK)

#143 Nanocrystalline nickel synthesis by pulsed current

A. Boukhouiète¹, S. Boumendjel²

¹ Univ. Badji-Mokhtar, Annaba (DZ)

² Univ. Hassiba Benbouali-Chlef, Chlef (DZ)

#148 Influence of substrate bias on the properties and conformality of TiN thin films deposited by High Power Impulse Magnetron Sputtering (HiPIMS)

L. Seigneur¹, J. Barbé^{1,2}, M.P. Besland¹

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#149 Plasma-grown vertically oriented graphene for supercapacitor electrodes

A. Vesel, R. Zaplotnik, G. Primc

Jozef Stefan Institute - Ljubljana (SI)

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DEPO / Plasma-assisted deposition, coatings and layers (*following*)

#158 Utilizing gas rarefaction to optimize preferential metal ion acceleration for epitaxial AlN growth on Silicon(111)

N. Behravan¹, T. Pitonakova², T. Terzic³, A. Farhadizadeh¹, M. Deluca⁴, M. Moridi⁴, D. Solonenko⁴, D. Lundin¹

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POSTER SESSIONS

Poster Session #2 – Wednesday 24 September (16:35 – 18:30)

PSURF / Plasma surface processing

- #032 Stability of expanded austenite during annealing in vacuum

S. Mändl, D. Manova

Leibniz Institute of Surface Engineering (IOM) - Leipzig (DE)

- #074 Atomic Layer Etching of SiO₂ using CF₄ plasma in deposition regime at cryogenic temperature

T. Tillocher¹, M. Adjabi¹, J. Nos¹, S. Iseni¹, G. Cunge², M. Kogelschatz², P. Lefaucheux¹, L. Becerra¹, E. Despiau-Pujo², R. Dussart¹

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- #079 Novel atmospheric-pressure plasma curing of anti-corrosion transparent silicon-based coating

P. Ghourchi Beigi, L. Zahedi, R. Krumpolec, D. Kováčik

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- #133 Enhancing fiber/matrix interface in bio-based composites by cold plasma treatment:

a step towards better fluid sealing

F. Perrier-Michon¹, S.A.E. Boyer², A. Burr², V. Rohani¹

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- #144 Regulation of peripheral plasma characteristics via engineered alterations in electrode shielding materials under a direct current-biased power configuration

C. Park^{1, 2}, J. Cho³, G. Woo⁴

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- #150 Optimizing active screen plasma nitriding of AISI 316L through alternative approaches: reactor conditioning and argon addition

A. Adami Vidal, R. Hugon, C. Noël, T. Czerwiec, G. Marcos

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NANO / Plasma nanotechnologies

- #012 Photoluminescent ZnO-SiO₂ nanocomposites prepared by a hybrid process coupling aerosol and Plasma Enhanced Chemical Vapour Deposition
M. Richard-Plouet¹, J. Chevet¹, M. Feron^{2,3}, A. Granier¹, M. Kahn³, R. Clergereaux², A. Gouillet¹
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- #087 Pulsed laser sources for nanometer-scaled complex materials and devices
M. Gireau¹, F. Du², J. Youssef^{3,4}, S. Vergnole⁴, G. Humbert³, S. Zeng², C. Champeaux¹, F. Dumas-Bouchiat¹
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GROM / Thin films growth and modelling

- #043 Influence of discharge parameters on the properties of TiO₂ films grown by reactive Bipolar HiPIMS discharges
S. Debnarova¹, M. Michiels^{1,2}, S. Konstantinidis¹
¹ Plasma-Surface Interaction Chemistry, Univ. Mons, Mons (BE)
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- #127 Multisource deposition conditions prediction towards required composition of thin films
J. Gutwirth¹, T. Halenovič¹, S. Šlang¹, V. Nazabal^{2,1}, P. Němec¹
¹ Univ. Pardubice - Pardubice (CZ)
² Univ. Rennes - Rennes (FR)

DEPO / Plasma-assisted deposition, coatings and layers

- #002 Influencing the properties of TiN and (Ti,Al)N hard coatings by modifying their composition and structural design
D. Munteanu¹, C. Lopes², I. Borsan¹, C. Gabor¹, M.S. Rodrigues², A. Ferreira², F. Macedo², E. Alves³, N.P. Barradas³, F. Vaz²
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- #011 HEA thin films as protective barrier against carbon diffusion during SPS
A. Besnard¹, M. El Garah², F. Sanchette², Y. Pinot³, R. Charvet⁴, M.R. Ardigo-Besnard⁴, F. Herbst⁴, N. Geoffroy⁴
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DEPO / Plasma-assisted deposition, coatings and layers (*following*)

#014 Thermodynamic modeling and experimental investigation of Ti PVD coatings as protective barriers against carbon diffusion during SPS

Y. Pinot¹, R. Charvet², M.R. Ardigo-Besnard², F. Baras², S. Le Gallet², F. Herbst², N. Geoffroy², A. Besnard³

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#035 Reversible functionalization of citronellal plasma polymers - towards pH responsive thin films

J. Carneiro De Oliveira, P. Covin, A. Airoudj, F. Bally-Le Gall, V. Roucoules

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#066 Nanostructuring of bismuth oxyfluoride thin films by oblique angle deposition for CO₂ photoconversion

A.E. Kabouia¹, A. Bousquet¹, S. Roth², A. Bonduelle², M. Richard-Plouet³, M. Le Granvalet³, R. Smaali⁴, E. Centeno⁴

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#134 Discriminating between morphological and chemical effects on the antibacterial properties of metal thin films through laser surface structuring

A-L. Thomann¹, P. Birnal¹, F. Brûlé-Morabito², B. Aspe¹, N. Semmar¹, P. Andreazza³, E. Bourhis³, P. Brault¹, M. Cavarroc⁴, A. Sauldubois¹, T. Vaubois⁴, E. Menou⁴, A. Caillard¹, C. Andreazza³

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#142 Nanostructure engineering and properties enhancement of Cu-based films by Zr and Ta alloying

M. Zhadko, A. Benediktová, J. Houška, R. Čerstvý, P. Baroch, P. Zeman

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#151 Atomic Layer Deposition of ZnO on fullerene: comparing thermal and plasma-enhanced approaches towards a photoactive nanocomposite

R. Del Sole^{1, 2}, A. Milella^{1, 2}, F. Fracassi^{1, 2}, P. Parlanti³, M. Gemmi³, A.M. Coclite^{4, 5}, F. Palumbo²

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#159 Recyclable thin coatings deposited by mean of plasma-assisted techniques on polymer foils for food packaging applications

F. Delfin^{1, 2}, C. Forsich¹, M. Schachinger¹, S. Augl¹, S. Brühl², C. Burgstaller¹, D. Heim¹

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MODIDD / Modelling, diagnostics and data-driven optimization of plasma processes

#009 Pure ammonia microwave discharges: a global model

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#017 Rate coefficients of the N + H + M(Ar, N₂) → NH + M recombination reaction in flowing afterglows of microwave plasmas

A. Ricard, V. Ferrer, J.P. Gardou, F. Marchal, J.P. Sarrette

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#059 Experimental investigations on the impact of gas flow on the propagation dynamics of a pulsed-driven μm-scale plasma jet

Y. Agha¹, K. Giotis^{1,2}, D. Stefan¹, L. Invernizzi¹, H. Hoeft³, P. Svarnas², K. Gazeli¹, G. Lombardi¹

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#098 Modelling N₂-H₂ for ammonia production

C. Pintassilgo^{1,2}, S. Baghel¹, M. Budde³, A. Gonçalves¹, O. Guaitella³, L. Marques⁴, P. Pereira¹, N. Pinhão¹, L.L. Alves¹

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#100 Ion energy distribution function measurement in hybrid HiPIMS with carbon target

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#126 Optimizing ECR plasma ashing for high yield during spintronic sensor fabrication on 200mm wafers

F. Favita¹, S. Cardoso^{1,2}

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#137 Enhancing surface emission in micro-gap atmospheric discharge via harmonic excitation

Y. Liu¹, N. Le Thomas^{2,3}, C. Leys¹, A. Nikiforov¹

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#156 Spectroscopy study of the LTE condition in the Laser Induced Breakdown used for the chlorine ion determination in building materials

M. Garcia Martinez, J. Mateo Calvo, A. Rodero Serrano

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